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APPLICATION NO.	FILINO DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/043,257	01/14/2002	Tomoyuki Saraki	0819-0732	7432
22304 7	590 94/07/2003			
NIXON PEABODY, LLP			EXAMINER	
8180 GREENSBORO DRIVE SUITE 800			RAO, SHRINIVAS H	
MCLEAN, VA 22102			ARTUNIT	PAPER NUMBER
			2814	
			DATE MAILED: 04/07/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
. '	10/043,257	SASAKI ET AL.				
Office Action Summary	Examiner	Art Unit				
	Steven H. Rao	2814				
Th MAILING DATE of this communication app ars on the cover sheet with the correspond nce address Period for Reply						
A SHORTEMED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provision of 3 CFR 1. after 5UK (8) MONTHS from the mailing date of this communication. If the period for reply specified above lies than thirt (9) days, a repl after 5UK (8) MONTHS from the mailing date of this communication. If the period for reply well the period is the sharp of 100 days, a repl after the period of 100 days and	136(a) In no event, however, may a five within the statutory minimum of the will apply and will expire SIX (6) MG, cause the expilication to become	reply be limely filed irty (30) days will be considered timely. NTHS from the making date of this communication ABANDONED (35 U.S.C. 6 133).				
Responsive to communication(s) filed on 23.	December 2002 .					
2a) This action is FINAL. 2b) ☑ The	nis action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims						
4) Claim(s) 1-32 is/are pending in the application						
4a) Of the above claim(s) 3-32 is/are withdrawn from consideration.						
5) Claim(s)is/are allowed.						
6) Claim(s) 1 and 2 is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) 1-32 are subject to restriction and/o	r election requirement.					
Application Papers						
9) The specification is objected to by the Examiner.						
10) ☑ The drawing(s) filed on 06 May 2002 is/are: a) ☑ accepted or b) ☐ objected to by the Examiner.						
Applicant may not request that any objection to the						
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action. 12) The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13) △ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) ⊠ All b) ☐ Some * c) ☐ None of:						
1. ⊠ Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No.						
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.						
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).						
 a) The translation of the foreign language pro 15) Acknowledgment is made of a claim for domest 						
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) Z	5) Notice of	Summary (PTO-413) Paper No(s) Informal Patent Application (PTO-152)				

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DETAILED ACTION

Priority

Receipt is acknowledged of paper submitted under 35 U.S.C. 119(a)-(d), claiming priority from Japanese Patent Application No. 10-164594 filed on June 06, 12, 1998 which papers have been placed of record in the file.

Flection/Restrictions

Applicant's election without traverse of claims 1-2 in Paper No. 9 (and the interview summary of 4/01/03) is acknowledged.

Claims 3-32 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected embodiments, there being no allowable generic or linking claim. Election was made without traverse in Paper No. 9 (and Interview summary).

Drawings

The drawings filed on 4/05/02 have been accepted by the drafts person.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

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(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-2 are rejected under 35 U.S.C. 102(b) as being anticipated by Lee et al. (U.S. Patent No. 5.872.061, hereinafter Lee).

With respect to claim 1, Lee describes a method of manufacturing an electronic device including the steps of :

- (a) forming on an underlying layer (Lee fig. 5 # 30, col.7 line 28), an insulating film made from one of an oxide film, a nitride film, an oxy nitride film, an organic film and an organic-inorganic hybrid film (Lee fig. 5 # 32, col. 7 lines 50-58).
- (b) forming a resist pattern on said insulating film (Lee fig. 5 # 34 aand b, col. 7 lines 63-64)
- forming an insulating film pattern by etching said insulating film with said resist pattern used as a mask (Lee fig. 6, col. 7 lines 62-67);
- (d) conducting plasma treatment on exposed portions of said underlying layer and said insulating film pattern without removing said resist pattern after $\frac{1}{8}$ © (Lee fig. 6 , col. 8 lines 26)
- (e) etching said underlying layer with said resist pattern and said insulating film as a mask. (Lee fig. 6, col. 8 lines 40-43).

With respect to claim 2, Lee describes the claim of claim, wherein said plasma treatment is conducted by using a gas including at least one of N_2 gas, an O_2 gas and an inert gas in the step (d) (Lee table 1 col.18-oxygen gas, col. 8 line 36 argon-inert gas).

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Any inquiry concerning this communication or earlier communication from the examiner should be directed to Steven H. Rao whose telephone number is (703) 306-5945. The examiner can normally be reached on Monday- Friday from approximately 7:00 a.m. to 5:30 p.m.

Any inquiry of a general nature or relating to the status of this application should be directed to the Group receptionist whose telephone number is (703) 308-0956. The Group facsimile number is (703) 308-7724.

Steven H. Rao

Patent Examiner

April 01, 2003.

ONG PHAMME